

EAST

L Number	Hits	Search Text	DB	Time stamp
2	56	((((cyanoacrylate or cyanoacrylates or (cyano adj2 (acrylic acrylate\$1))) and (resist resists photoresist photoresists photosensitive)) and ((acid adj (generator generators)) or onium)) and 430/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:28
3	3	"6635401"	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:17
5	45	(((((cyanoacrylate or cyanoacrylates or (cyano adj2 (acrylic acrylate\$1))) and (resist resists photoresist photoresists photosensitive)) and ((acid adj (generator generators)) or onium)) and 430/\$.ccls.) and (etch etching)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 17:14
6	0	6635401.URPN.	USPAT	2004/05/13 16:15
7	2	"20020187419"	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:18
9	0	20020187419.URPN.	USPAT	2004/05/13 16:18
10	1	"200293263"	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:19
11	4	"2002093263"	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:19
12	26	dammel-ralph\$.in. and cyano	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:20
13	26	dammel-ralph\$ and cyano	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:20
14	52	dammel\$ and cyano	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:20
15	3	(cyanoacrylate or cyanoacrylates or (cyano adj2 (acrylic acrylate\$1))) and (li-wenjie\$.in. varanasi-push\$.in.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:27
16	1	(((((cyanoacrylate or cyanoacrylates or (cyano adj2 (acrylic acrylate\$1))) and (resist resists photoresist photoresists photosensitive)) and ((acid adj (generator generators)) or onium)) and ((cyano and (switchable)) and 430/\$.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:28
1	43	(cyano and (switchable)) and 430/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:29
17	8	((cyano and (switchable)) and 430/\$.ccls.) and (etch etching)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 16:29
27	1952	(photoresist resist resists photoresists) and (metal metals) and (ion with etch\$3) and 430/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 17:15
28	137	((photoresist resist resists photoresists) and (metal metals) and (ion with etch\$3) and 430/\$.ccls.) and (intermediate adj layer\$1)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/13 17:16